

Sir:

PATENT APPLICATION Docket No. 11675.163.2

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:)		
	Terry N. Williams))		
Serial No.:	09/761,375) Art Unit		
Filed:	January 16, 2001) 2882		
For:	BUFFERED RESIST PROFILE ETCH OF A FIELD EMISSION DEVICE STRUCTURE))		
Examiner:	Jurie Yun	TECHN		
Confirmation No.:	5328	LECHNOLOGA	DEC 2	RECEIV
	AMENDMENT AND RESPONSE	200 CE	0 2002	DEAN
Commissioner for Patents Washington, D. C. 20231		7800	,))).	

In response to the Office Action mailed from the United States Patent and Trademark Office on August 2, 2002, please enter the following amendments and remarks into the file of the above-identified application.